

4. (Original) A composition for controlling odor as in Claim 3, wherein the organic acid is an aliphatic acid.

5. (Original) A composition for controlling odor as in Claim 4, wherein the aliphatic acid is a hexanedioic acid.

6. (Currently Amended) A method for controlling odor produced by human waste retained in a disposable sanitary product, comprising the steps of;

- a) providing a base substrate material,
- b) providing a odor control compound,
- c) the odor control compound comprising an admixture of a hydroxydiphenyl ether and a modified acid carrier,
- d) applying the odor control compound in the form of said admixture topically to the base substrate material,
- e) subsequently forming the treated base substrate material into a component material for a disposable sanitary product.

7. (Original) A method for controlling odor as in Claim 6, wherein the base material is selected from the group consisting of nonwoven fabrics, woven fabrics, polymeric films, and the combinations thereof.

8. (Currently Amended) A method for controlling odor produced by human waste retained in a disposable sanitary product, comprising the steps of:

- a) providing a base substrate material formed from a polymeric composition containing therein a hydroxydiphenyl ether,
- b) applying a modified acidic carrier to the base substrate material,

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c) subsequently forming the treated base substrate material into a component material for a disposable sanitary product.

9 (New) A composition for controlling odor in accordance with claim 1,

wherein:

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said composition is provided on said base substrate material by providing said hydroxydiphenyl ether in a polymeric composition from which said base substrate material is formed, and thereafter applying said modified acidic carrier to said base substrate material.

10. (New) A composition for controlling odor in accordance with claim 1,

wherein:

said composition is provided on said base substrate material by forming an admixture of said hydroxydiphenyl ether and said modified acidic carrier, and topically applying said admixture to said base substrate material.--